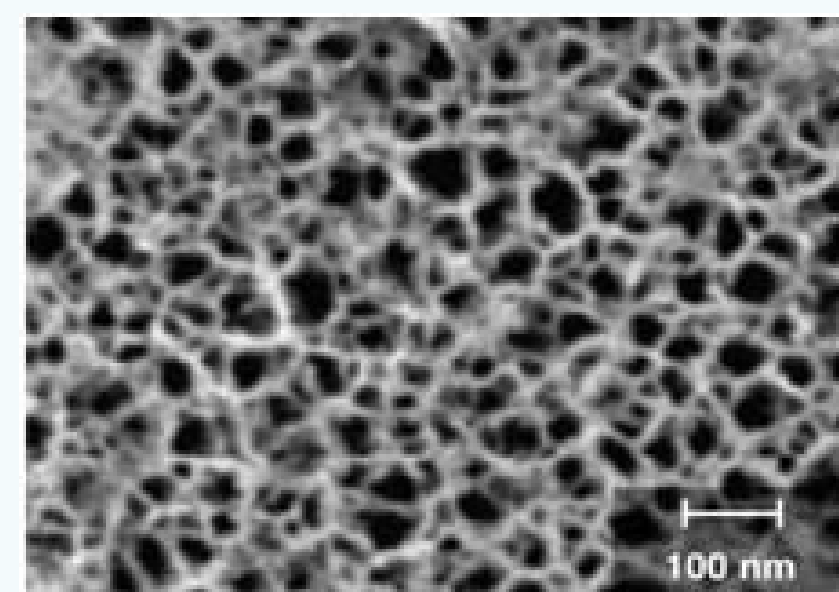
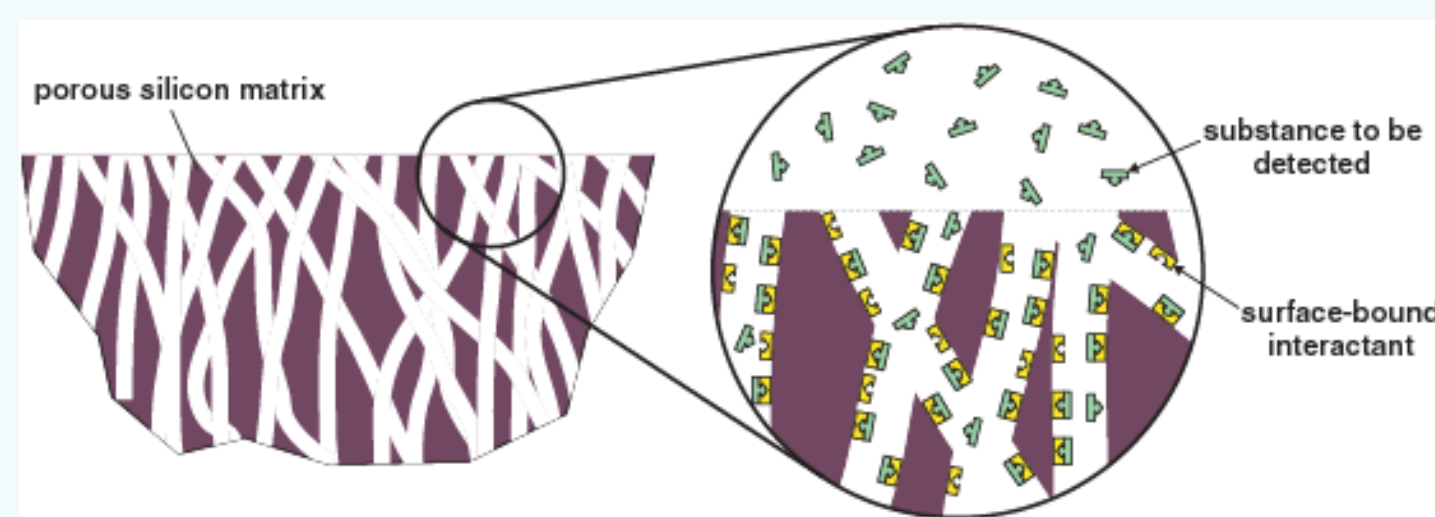


The Loss Mechanism of Nanoporous Silicon Optical Waveguide for Biochemical Sensors

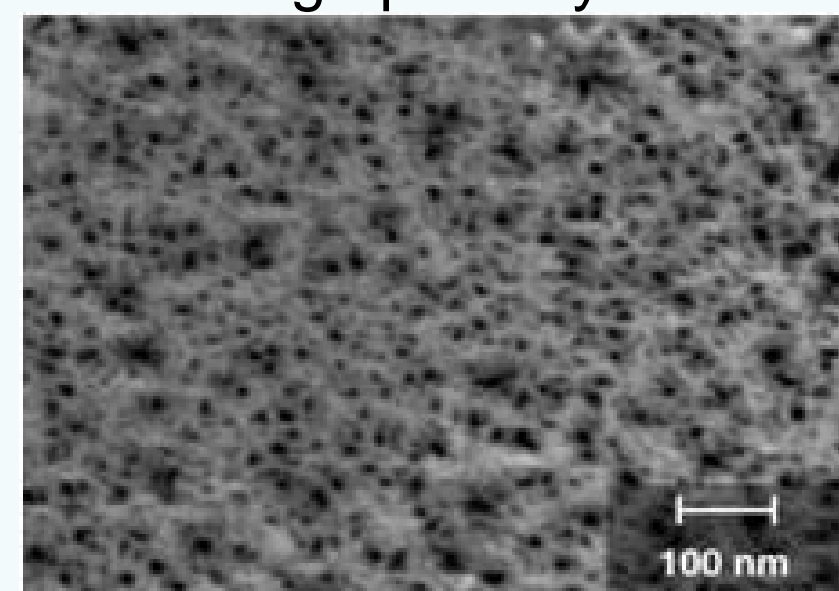
Susu Yan, Shu Zee Alencious Lo, and Professor Thomas E. Murphy

Introduction

- Nanoporous Silicon
 - Large surface area
 - Large range of porosities, refractive indices
- Nanoporous Silicon Optical Waveguide
 - Vertical confinement: multilayer structure
 - Horizontal confinement: laser local oxidation
- Optical biochemical sensors



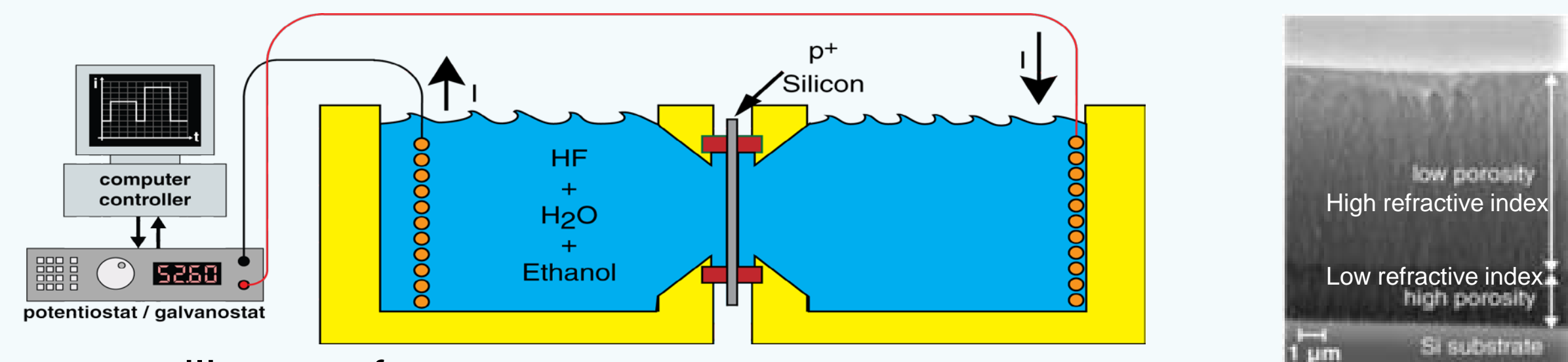
High porosity



Low porosity

Fabrication

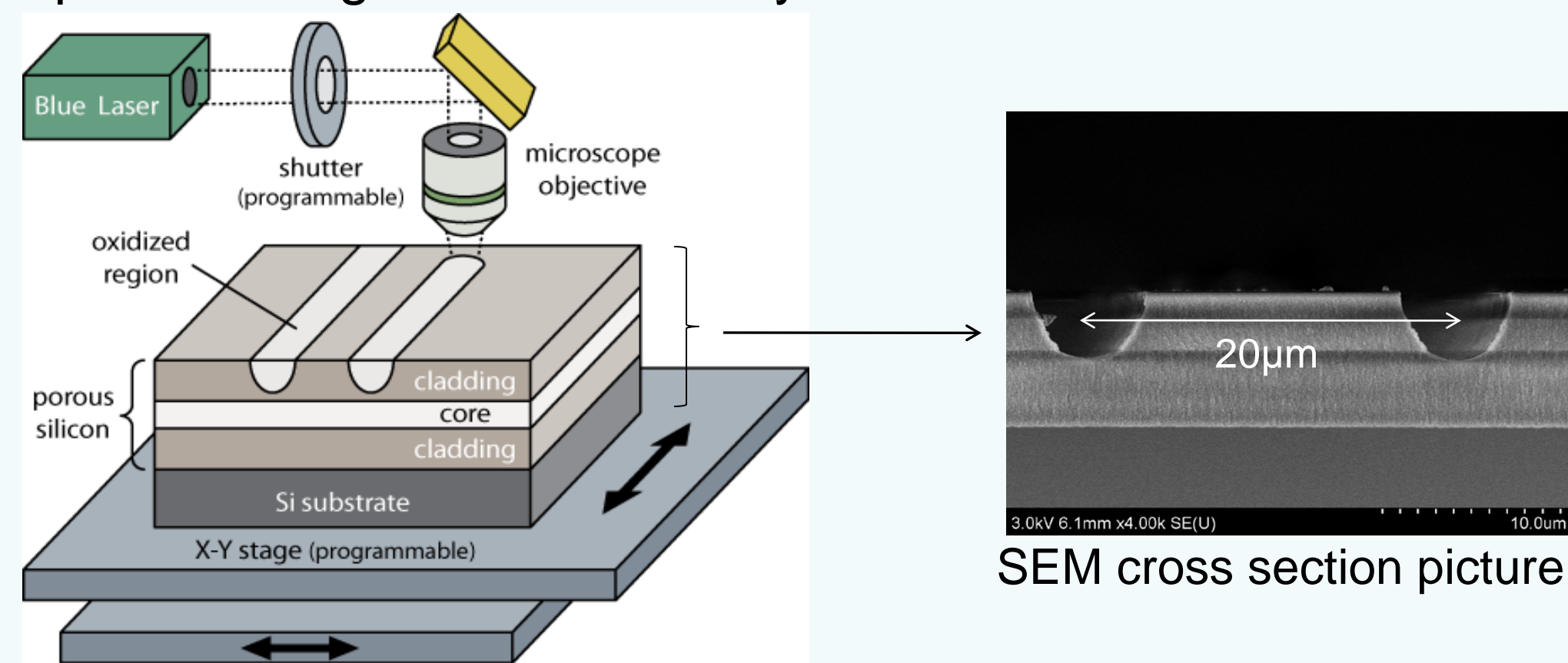
- Electrochemical anodization



- p++ silicon wafer
- Applying different current densities → different porosities
- High porosity → low refractive index
- Low porosity → high refractive index

- Laser writing system

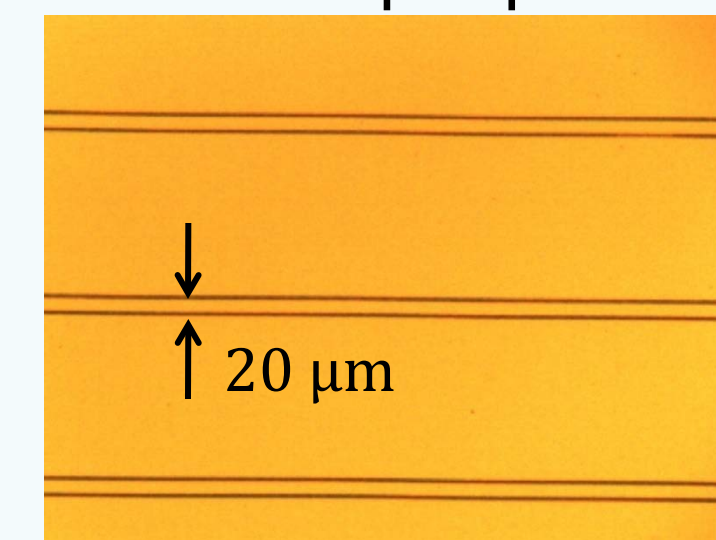
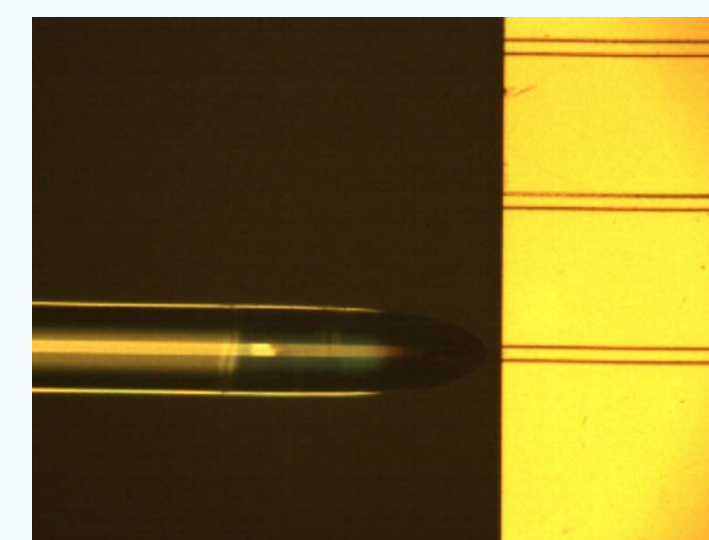
- Optical waveguide achieved by laser local oxidation



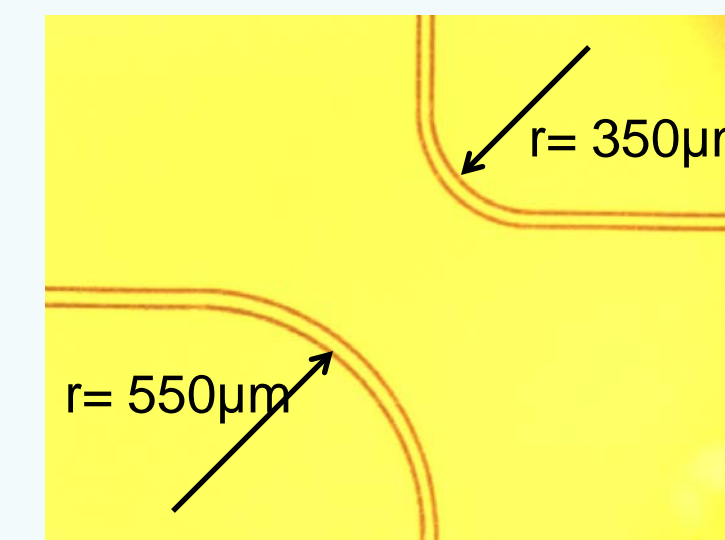
SEM cross section picture

Experimental Arrangement

- Fiber coupling optical waveguide measurement
 - 1550nm wavelength with 0.879mW input power

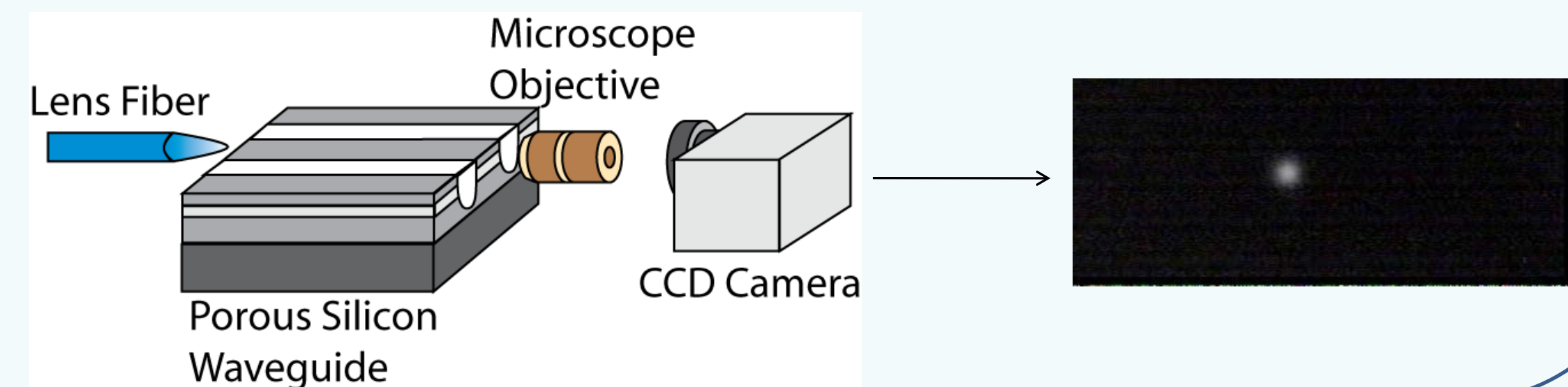


Straight waveguide



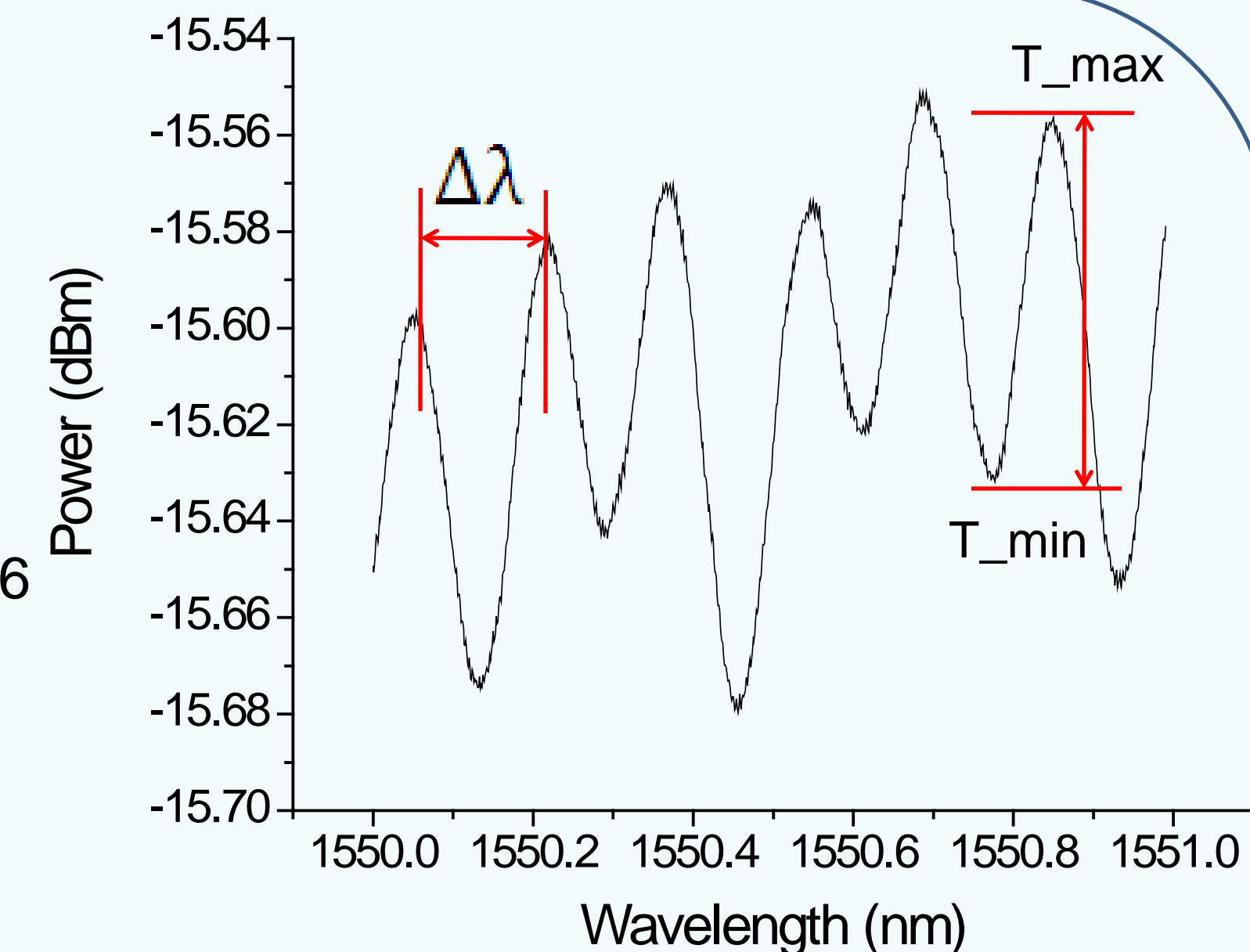
Bent waveguide

- Single mode test



Result

- Output power = 0.112mW
- Total loss = -8.948dB
- Fabry PÉrot interferometry
 - Interference fringe
 - Effective refractive index = 1.6
 - Propagation loss = -13dB/cm
 - Coupling loss = -2.63dB



Conclusion

- Propagation loss is the main loss.
- Loss analysis of porous silicon waveguide based on Fabry PÉrot interferometry has been achieved.
- Optimized parameters to obtain low loss nanoporous silicon optical waveguide which can be used as biochemical sensors.
- Mach-Zehnder and other on-chip interference devices can be achieved in the future using the optimized parameters.

Acknowledgment

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